

U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE Application Number 09/039,438 **REQUEST FOR CONTINUED EXAMINATION (RCE)** TRANSMITTAL Subsection (b) of 35 U.S.C. §132, effective on May 29, 2000, provides for continued examination of an utility or plant application filed on or after June 8, 1995 See The American Inventors Protection Act of 1999 (AIPA). Filing Date March 16, 1998 First Named Inventor Woo Sup SHIN, et al. Group Art Unit 1763 **Examiner Name** A. Powell Attorney Docket No. 8733.120.01 This is a Request for Continued Examination (RCE) under 37 C.F.R. § 1.114 of the above-identified application. 37 C.F.R. § 1.114 is effective on May 29, 2000. If the above-identified application was filed prior to May 29, 2000, applicant may wish to consider filing a continued prosecution application (CPA) under 37 C.F.R. § 1.53(d) (PTO/SB/29) instead of a RCE to be eligible for the patent term adjustment provisions of the AIPA. See Changes to Application Examination and Provisional Application Practice, Interim Rule, 65 Fed. Reg. 14865 (Mar. 20, 2000), 1233 Off. Gaz. Pat. Office 47 (Apr. 11, 2000), which established RCE practice. Submission required under 37 C.F.R § 1.114 1. Previously submitted a. ☐ Consider the amendment(s)/reply under 37 C.F.R. § 1.116 previously filed on i. (Any unentered amendment(s) referred to above will be entered.) ☐ Consider the arguments in the Appeal Brief or Reply Brief previously filed on ii. PECE/VED

72/2002 iii. ☐ Other Enclosed b. × i. ☑ Amendment/Reply ii. ☐ Affidavit(s)/Declaration(s) ☐ Information Disclosure Statement (IDS) iii. iv. 2. Miscellaneous Suspension of action on the above-identified application is requested under 37 C.F.R. § 1.103(c) for a. a period of ____ months. (Period of suspension shall not exceed 3 months; Fee under 37 C.F.R. § 1.17(i) required.) b. ◱ Other 3. Fees (The RCE fee under 37 C.F.R. § 1.17(e) is required by 37 C.F.R. §1.114 when the RCE is filed.) The Director is hereby authorized to charge the following fees, or credit any overpayments, to a. Deposit Account No. 50-0911. ☐ RCE fee required under 37 C.F.R. § 1.17(e) i. ii. ☐ Extension of time fee (37 C.F.R. §§ 1.136 and 1.17) iii. ☐ Other

Check in the amount of \$ 740.00 enclosed

Rebecca A. Goldman

Payment by credit card (Form PTO-2038 enclosed)

SIGNATURE OF APPLICANT, ATTORNEY, OR AGENT REQUIRED

Registration No.

Date

41,786

b.

c.

Name

Signature

X

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE								
INVENTOR(S) Woo Sup SHIN et al.								
SERIAL NO: 09/039,438								
FILING DATE: March 16, 1998								
FOR: ETCHING APPARATUS								
AMENDMENT TRANSMITTAL								
COMMISSIONER FOR PATENTS								
WASHINGTON, D FOR	NUMBER			NUMBER	RATE		CALCULATIONS	
		FILED			EXTRA		010	#00.00
FOTAL CLAIMS		25 6	- 20 - 3	+	5	<u> </u>	\$18= \$84=	\$90.00 \$252.00
NDEPENDENT CLAIMS □ MULTIPLE DEPENDEN				<u> =</u>		<u>x</u>	\$280=	\$2,52.00
MULTIPLE DEPENDENT CLAIMS (If applicable) + TOTAL OF ABOVE CALCUL.								
□ REDUCTION BY 50% FOR FILING BY SMALL ENTITY \$0.00								
■ EXTENSION OF TIME FEE						=	\$1,440.00	
								\$1,782.00
Please charge Deposit Account No. 50-0911 in the amount						nt of	A duplicate copy of this sheet is enclosed.	
A check in the amount of \$1,782.00 to cover the filing fee is enclosed.								s enclosed.
The Commissioner is hereby authorized to charge any additional fees which may be required for the papers being filed herewith and for which no check is enclosed herewith, or credit any overpayment to Deposit Account No. 50-0911. A duplicate copy of this sheet is enclosed.								
						Respectfully Submitted, LONG ALDRIDGE & NORMAN LLP		
Date: January 16, 2002						Abec		
Sixth Floor 701 Pennsylvania Ave., N.W. Washington, D.C. 20004 Tel. (202) 624-1200 Fax. (202) 624-1298 Registration No. 41,786								

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TC 1700

Docket No. 8733.120.01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

Woo Sup SHIN, et al.

Serial No.: 09/039,438

Filed: March 16, 1998

For: Etching Apparatus

Group Art Unit: 1763

Examiner: A. Powell

R.ZERV190N

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<u>AMENDMENT</u>

Commissioner of Patents Washington, D.C. 20231

Sir:

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TO 1700

Prior to issuance of a first Office Action after RCE, please amend the above-referenced application as follows:

IN THE CLAIMS:

Please ADD new claims as follows:

--21. (New) An etching apparatus for etching a glass substrate comprising: a first tank including a first etchant;

an etch bath for immersing the glass substrate in the first etchant, the etch bath having a bubble plate for generating nitrogen bubbles, the bubble plate being connected to a nitrogen inlet pipe, the nitrogen inlet pipe being connected to a nitrogen supply line, the etch bath being connected to the first tank and receiving the first etchant, the etch bath containing a residual etchant including a diluted etchant and residue material after the glass substrate is etched with the first etchant to uniformly reduce a thickness of the glass substrate;

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